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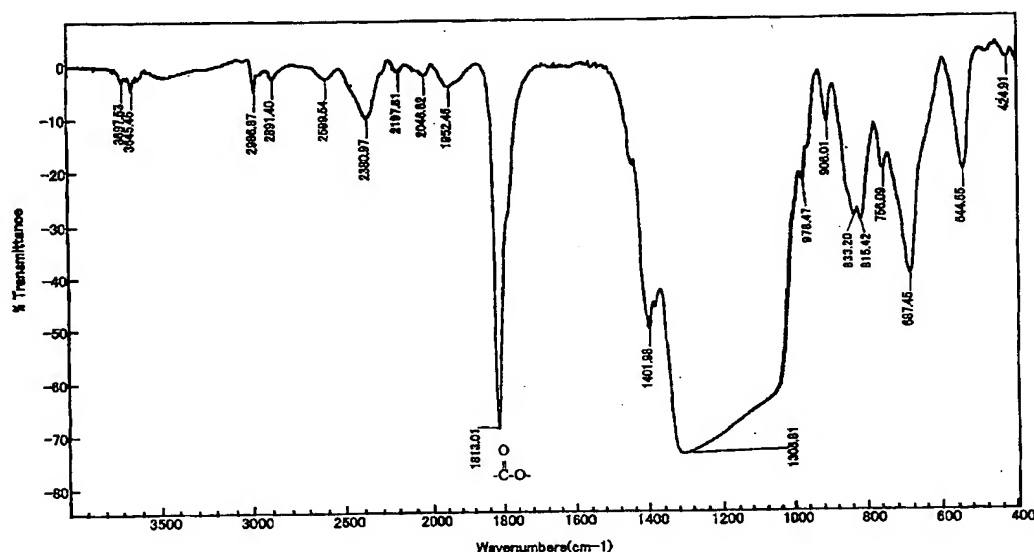
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(54) Title: PERFLUOROPOLYETHER ESTER COMPOUND, LUBRICANT AND MAGNETIC RECORDING MEDIUM

(54) 発明の名称: パーフルオロポリエーテルエステル化合物、潤滑剤及び磁気記録媒体



(57) **Abstract:** Novel perfluoropolyether derivative having at least one ester bond and being useful as a lubricant whose decomposition temperature is 300°C or higher is obtained by performing esterification reaction between a perfluoropolyether diol having hydroxyls at both ends thereof and represented by the formula (1) and a perfluoropolyether dicarboxylic acid having carboxyls at both ends thereof and represented by the formula (2): HOCH₂-R-CH₂OH (1) HOOC-R'-COOH (2) wherein each of R and R' represents a perfluoropolyether group.

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DESCRIPTIONPERFLUOROPOLYETHER ESTER COMPOUND, LUBRICANT AND MAGNETIC
RECORDING MEDIUM

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TECHNICAL FIELD

The present invention relates to a novel
perfluoropolyether ester compound which is useful as a
lubricant, and to a lubricant and recording medium
10 employing same.

BACKGROUND ART

In hard disk devices for magnetic recording, because
the magnetic head contacts the hard disk a lubricant is
15 applied to the surface of the hard disk. Known lubricants
of this kind include a perfluoropolyether diol having
hydroxyl groups at both ends (Z-DOL, Ausimont), a
perfluoropolyether dicarboxylic acid having carboxyl groups
at both ends (Z-DIAC, Ausimont), and a perfluoropolyether
20 tetraol having propylene glycol residues at both ends (Z-
TETRAOL, Ausimont).

A perfluoropolyether ester derivative has also been
proposed wherein a perfluoropolyether residue is bound to a
long-chain alkyl group or perfluoroalkyl group via an ester
25 bond (see Japanese Patent Application Laid-open No. H5-
194970).

However, because it is expected that the next generation of compact hard disk devices for magnetic recording which allow high-density recording will be mounted in passenger vehicles, in which the indoor
5 temperature is relatively high, they will need to be more heat-resistant, and in particular the lubricant applied to the outer surface of the hard disk will need to be heat-resistant at 300°C or more.

In the case of the commercial lubricants described
10 above (perfluoropolyether diol, perfluoropolyether dicarboxylic acid, perfluoropolyether tetraol), however, the problem is that the decomposition temperature is about 270°C at most and the extinction temperature is about 450°C at most, so the requirement of heat resistance at 300°C or
15 more is not met. Even in the case of the perfluoropolyether ester compound described in Japanese Patent Application Laid-open No. H5-194970, the decomposition temperature is no more than about 280°C at most so the requirement of heat resistance at 300°C or more
20 is not met.

One possible way of improving the heat resistance of these perfluoropolyether derivatives which are lubricants would be to remove from the molecule the functional groups which are starting points for decomposition, but this is
25 not a practical response considering the decrease in adhesion with the hard disk surface. The molecular weight

of the perfluoropolyether derivative could also be increased by increasing the number of repeating units thereof, but this would be unlikely to yield a perfluoropolyether derivative with a narrow molecular weight distribution and stable characteristics.

It is an object of the present invention to resolve the aforementioned problems of background art and allow a novel perfluoropolyether derivative which is useful as a lubricant and exhibits a decomposition temperature of 300°C or more to be provided in an industrially convenient way.

DISCLOSURE OF THE INVENTION

The inventors perfected the present invention when they discovered that a compound wherein at least two perfluoropolyether residues are bound by ester binding is a novel compound exhibiting a decomposition temperature of 300°C or more.

That is, the present invention provides a novel perfluoropolyether ester compound having at least one ester bond, wherein the ester compound is obtained by an esterification reaction between a perfluoropolyether diol having hydroxyl groups at both ends thereof and represented by the formula (1) and a perfluoropolyether dicarboxylic acid having carboxyl groups at both ends thereof and represented by the formula (2):



wherein each of R and R' is a group selected independently from the following perfluoroether groups R¹ through R⁴:

- 5 R¹: -CF₂-(OCF₂CF₂)_m-(OCF₂)_n-OCF₂-
 R²: -(CF₂O)_j-(CF₂CF₂O)_k-(CF₂O)_l-CF₂-
 R³: -(CF₂CF₂CF₂O)_o-CF₂CF₂-
 R⁴: -(CF₂CF(CF₃)O)_p-CF₂-

wherein m, n, j, k, l, o and p independently represent
 10 integers of 1 to 100.

Moreover, the present invention provides a lubricant containing this novel perfluoropolyether ester compound.

In addition, the present invention provides a magnetic recording medium having at least a magnetic layer formed on
 15 a non-magnetic support, wherein an applied film of lubricant containing the novel perfluoropolyether ester compound described above is formed on the surface of the magnetic layer.

20 BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is an IR chart of the perfluoropolyether diol of Formula (1) used in Example 1.

Figure 2 is an IR chart of the perfluoropolyether dicarboxylic acid of Formula (2) used in Example 1.

Figure 3 is an IR chart of the perfluoropolyether ester compound obtained in Example 1.

Figure 4 is an IR chart of the perfluoropolyether dicarboxylic acid of Formula (2) used in Example 2.

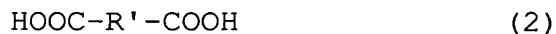
5 Figure 5 is an IR chart of the perfluoropolyether ester compound obtained in Example 2.

BEST MODE FOR CARRYING OUT THE INVENTION

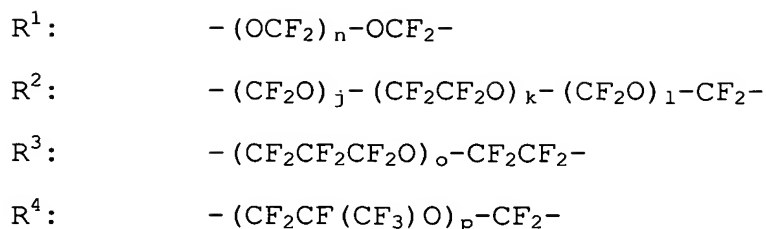
The present invention is explained in detail below.

10 The present invention is a novel perfluoropolyether ester compound having at least one ester bond and obtained by an esterification reaction between a perfluoropolyether diol having hydroxyl groups at both ends thereof and a perfluoropolyether dicarboxylic acid having carboxyl groups
15 at both ends thereof.

The perfluoropolyether diol having hydroxyl groups at both ends is represented by the following Formula (1), while the perfluoropolyether dicarboxylic acid having carboxyl groups at both ends thereof is a compound
20 represented by the following Formula (2):

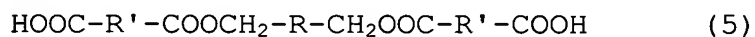
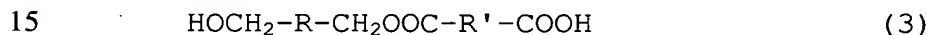


(wherein each of R and R' is any substitutional group selected independently from the following perfluoroether
25 groups R¹ through R⁴:



5 wherein m, n, j, k, l, o and p independently represent integers of 1 to 100.

The novel perfluoropolyether ester compound of the present invention is not particularly limited as to the number of ester bonds, but from the standpoint of stability
 10 it should preferably have one or two ester bonds, and examples include those having the following chemical structure formulas (3) through (5) in which perfluoropolyether residues are bound to both sides of an ester bond.



Specific examples of the novel perfluoropolyether ester compound of the present invention include preferably
 20 compounds in which R is $-\text{CF}_2-(\text{OC}_2\text{F}_4)_{m1}-(\text{OCF}_2)_{n1}-\text{OCF}_2-$ (wherein m1 and n1 are each independently numbers of 8 to 12) and R' is $-\text{CF}_2-(\text{OC}_2\text{F}_4)_{m2}-(\text{OCF}_2)_{n2}-\text{OCF}_2-$ (wherein m2 and n2 are each independently numbers of 8 to 12) in chemical structure formulas (3), (4) and (5), as well as compounds in which R
 25 is $-\text{CF}_2-(\text{OC}_2\text{F}_4)_{m1}-(\text{OCF}_2)_{n1}-\text{OCF}_2-$ (wherein m1 and n1 are each independently number of 8 to 12) and R' is $-\text{CF}_2-(\text{OC}_2\text{F}_4)_{m2}-$

$(\text{OCF}_2)_{n_2}-\text{OCF}_2-$ (wherein m_2 and n_2 are each independently numbers of 19 to 24) in chemical structure formulas (3), (4) and (5).

Regarding the molecular weight of the novel
5 perfluoropolyether ester compound of the present invention,
if the weight average molecular weights of the
perfluoropolyether diol of formula (1) and the
perfluoropolyether dicarboxylic acid of formula (2) are too
small the heat resistance temperature of the product will
10 be less, while if they are too large reactivity will be less,
so they are each preferably between 1500 and 4000 or more
preferably between 1800 and 3800.

The perfluoropolyether ester compound of the present
invention can be manufactured by heating and agitating the
15 perfluoropolyether diol of formula (1) and the
perfluoropolyether dicarboxylic acid of formula (2) in a
solvent (such as PF5080 (Sumitomo 3M), FC77 (Sumitomo 3M)
or Vertrel XF (Mitsui-Dupont Fluorochemical)) in the
presence of an esterification catalyst such as p-
20 toluenesulfonic acid or the like while removing the
resulting water. Preferably it is manufactured by an
industrially convenient bulk polymerization method which is
esterification by heating and agitating the
perfluoropolyether diol of formula (1) and the
25 perfluoropolyether dicarboxylic acid of formula (2) without
solvent at a temperature of 100 to 180°C. When it is

manufactured by bulk polymerization it can be used as a lubricant without any industrial refinement operations such as recrystallization or the like.

5 The novel perfluoropolyether ester compound of the present invention explained above is useful as a highly heat-resistant lubricant with a decomposition temperature of 300°C or more.

10 When the novel perfluoropolyether ester compound of the present invention is used as a lubricant the lubricant may be composed solely of the perfluoropolyether ester compound, or additives such as extreme pressure agents or rust-proofing agents can be added appropriately according to the intended use of the lubricant.

15 A lubricant containing the novel perfluoropolyether ester compound of the present invention can be used favorably for application to the surface of a magnetic recording medium. Consequently, a magnetic recording medium treated with a lubricant containing the novel perfluoropolyether ester compound of the present invention
20 has a structure in which at least a magnetic layer is formed on a non-magnetic support, and an applied film of highly heat-resistant lubricant containing the novel perfluoropolyether ester compound of the present invention is formed on the surface of the magnetic layer. Thus, such
25 as magnetic recording medium is particularly useful as the hard disk of a hard disk device for magnetic recording.

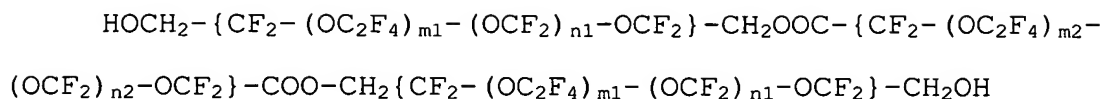
Configurations similar to those of the non-magnetic supports and magnetic layers which make up conventional known magnetic recording media can be adopted for the non-magnetic support and magnetic layer which make up the magnetic recording medium of the present invention.

EXAMPLES

The present invention is explained in detail below using examples.

10 Example 1

20 parts by weight of the perfluoropolyether diol of formula (1) having the IR chart of Figure 1 (weight average molecular weight = 1900, $R = -CF_2-(OC_2F_4)_m-(OCF_2)_n-OCF_2-$, $m = 10$, $n = 10$, Ausimont) and 10 parts by weight of the perfluoropolyether dicarboxylic acid of formula (2) having the IR chart of Figure 2 (weight average molecular weight = 3800, $R' = -CF_2-(OC_2F_4)_m-(OCF_2)_n-OCF_2-$, $m = 20$, $n = 20$, Ausimont) were placed in a reaction vessel equipped with an agitator and reacted for 2 hours at 160°C in a flow of nitrogen gas, to obtain a perfluoropolyether ester compound (weight average molecular weight 7800) corresponding to the aforementioned chemical structure formula (4) and having 2 ester bonds in the molecule. The exact structural formula of the resulting perfluoropolyether ester compound is as follows, and the IR chart thereof is shown in Figure 3.

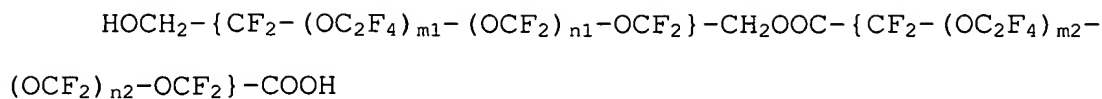


Comparative Example 1

The perfluoropolyether dicarboxylic acid of formula
 5 (2) (Z-DIAC4000, Ausimont) was purified, and the polymer was fractioned to obtain a perfluoropolyether dicarboxylic acid compound with a weight average molecular weight of 7100 having no ester bonds in the molecule.

Example 2

10 10 parts by weight of the perfluoropolyether diol of formula (1) having effectively the same IR chart as the IR chart of Figure 1 (weight average molecular weight = 1800, $R = -\text{CF}_2-(\text{OC}_2\text{F}_4)_{m1}-(\text{OCF}_2)_{n1}-\text{OCF}_2-$, $m1 = 10$, $n1 = 10$, Ausimont) and 10 parts by weight of the perfluoropolyether
 15 dicarboxylic acid of formula (2) having the IR chart of Figure 4 (weight average molecular weight = 2000, $R' = -\text{CF}_2-(\text{OC}_2\text{F}_4)_{m2}-(\text{OCF}_2)_{n2}-\text{OCF}_2-$, $m2 = 10$, $n2 = 10$, Ausimont) were placed in a reaction vessel equipped with an agitator and reacted for 2 hours at 160°C in a flow of nitrogen gas, to
 20 obtain the perfluoropolyether ester compound (weight average molecular weight 3800) of the aforementioned chemical structure formula (3) having 1 ester bond in the molecule. The exact structural formula of the resulting perfluoropolyether ester compound is as follows, and the IR
 25 chart thereof is shown in Figure 5.



Comparative Example 2

The perfluoropolyether dicarboxylic acid of formula
 5 (2) having no ester bonds in the molecule (Z-DIAC4000,
 Ausimont) was used as is (weight average molecular weight
 3800).

Comparative Example 3

Perfluorooctyl ethanol was reacted with the -COOH
 10 groups on both ends of the perfluoropolyether dicarboxylic
 acid (Z-DIAC4000, Ausimont) of formula (2) to obtain a
 perfluoropolyether fluoroalkyl diester compound having 2
 ester bonds in the molecule (weight average molecular
 weight 4800).

15 (Evaluation)

The decomposition temperatures and extinction
 temperatures of the perfluoropolyether derivatives obtained
 in Examples 1 and 2 and Comparative Examples 1 through 3
 were measured in accordance with JIS K0129. The results
 20 are shown in Table 1.

Table 1

	Weight average molecular weight	Number of esters	Decomposition temperature	Extinction temperature
Example 1	7800	2	380°C	500°C
Comparative Example 1	7100	0	330°C	450°C
Example 2	3800	1	380°C	500°C
Comparative Example 2	3800	0	270°C	450°C
Comparative Example 3	4800	2	280°C	450°C

It can be seen from Table 1 that the perfluoropolyether ester compounds of Example 1 and Example 2, which have perfluoropolyether residues on both sides of an ester, both have higher decomposition temperatures than perfluoropolyether derivatives (Comparative Example 1 and Comparative Example 2) of roughly the same molecular weight which lack esters (380°C for Example 1 vs. 330°C for Comparative Example 1, 380°C for Example 2 vs. 270°C for Comparative Example 2).

From the results for Example 1 and Example 2 it can also be seen that the decomposition temperature is also less dependent on molecular weight when an ester is present (there is no great change in decomposition temperature depending on molecular weight). This finding differs completely from the finding based on Comparative Example 1 and Comparative Example 2 that the decomposition temperature rises as the molecular weight rises in the case of a perfluoropolyether derivative having no esters.

Consequently, it is seen that the decomposition temperature can be raised without increasing the weight average molecular weight if a perfluoropolyether ester compound is manufactured by introducing perfluoropolyether residues on both sides of an ester.

In the case of the perfluoropolyether derivative of Comparative Example 3 which has two ester bonds but which has a perfluoroalkyl group rather than a perfluoropolyether residue on one side of the esters, the decomposition temperature was low, only 280°C. From this it is seen that introduction of perfluoropolyether residues on both sides of an ester bond is effective for raising the decomposition temperature.

Moreover, the extinction temperature was 500°C in the case of Examples 1 and 2 which had perfluoropolyether residues on both sides of the ester bonds, but 450°C in the case of Comparative Examples 1 through 3. Consequently, it is seen that introduction of perfluoropolyether residues on both sides of an ester bond is effective for raising the extinction temperature.

INDUSTRIAL APPLICABILITY

The novel perfluoropolyether ester compound of the present invention is a compound having one or more ester bonds, which is obtained by performing an esterification reaction between a perfluoropolyether diol having hydroxyl

groups at both ends thereof and a perfluoropolyether dicarboxylic acid having carboxyl groups at both ends thereof, and is therefor useful as a heat-resistant lubricant with a decomposition temperature of 300°C or more.